



IFW

PATENT APPLICATION

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re the Application of

Satoshi INOUE et al.

Group Art Unit: 2812

Application No.: 10/748,206

Filed: December 31, 2003

Docket No.: 040852.98

For: MANUFACTURING METHOD OF ACTIVE MATRIX SUBSTRATE , ACTIVE MATRIX
SUBSTRATE AND LIQUID CRYSTAL DISPLAY DEVICE

INFORMATION DISCLOSURE STATEMENT

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

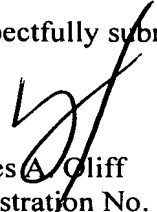
Sir:

Pursuant to 37 CFR §1.56, the attention of the Patent and Trademark Office is hereby directed to the reference(s) listed on the attached PTO-1449. Unless otherwise indicated herein, one copy of each reference is attached. It is respectfully requested that the information be expressly considered during the prosecution of this application, and that the reference(s) be made of record therein and appear among the "References Cited" on any patent to issue therefrom.

- ☒ 1. This Information Disclosure Statement is being filed (a) within three months of the U.S. filing date of this non-CPA application, OR (b) before the mailing date of a first Office Action on the merits in the present application. No certification or fee is required.
- ☒ 2. English language Abstracts of the non-English language references are attached hereto.

- ☒ 3. A computer-generated English language translation of the following Japanese Patent Publication has been obtained from the website of the Japanese Patent Office ([<http://www.jpo.go.jp>]), and is attached, but has not been reviewed for accuracy. See Reference 1-9.

Respectfully submitted,


James A. Oliff
Registration No. 27,075

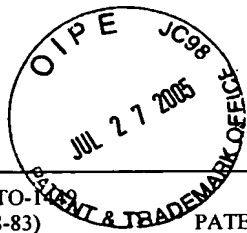
Yong S. Choi
Registration No. 43,324

JAO:YSC/mdw

Date: July 27, 2005

OLIFF & BERRIDGE, PLC
P.O. Box 19928
Alexandria, Virginia 22320
Telephone: (703) 836-6400

<p>DEPOSIT ACCOUNT USE AUTHORIZATION Please grant any extension necessary for entry; Charge any fee due to our Deposit Account No. 15-0461</p>

Sheet 1 of 1

Form PTO-1489 (REV. 8-83)		US Dept. of Commerce PATENT & TRADEMARK OFFICE		ATTY DOCKET NO. 040852.98		APPLICATION NO. 10/748,206	
INFORMATION DISCLOSURE STATEMENT (Use several sheets if necessary)				APPLICANT(S) Satoshi INOUE et al.			
				FILING DATE December 31, 2003		GROUP 2812	
U.S. PATENT DOCUMENTS							
EXAMINER INITIAL		DOCUMENT NUMBER	DATE	NAME	CLASS	SUB CLASS	
FOREIGN PATENT DOCUMENTS							
		DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUB CLASS	
	1	JP07-098460A (w/machine translation)	04/1995	Japan			
	2	JP08-250745A (w/machine translation)	09/1996	Japan			
	3	JP08-262474A (w/machine translation)	10/1996	Japan			
	4	JP08-262475A (w/machine translation)	10/1996	Japan			
	5	JP08-234796A (w/machine translation)	09/1996	Japan			
	6	JP08-278519A (w/machine translation)	10/1996	Japan			
	7	JP05-218365A (w/machine translation)	08/1993	Japan			
	8	JP08-240814A (w/machine translation)	09/1996	Japan			
	9	JP06-202160A (w/machine translation)	07/1994	Japan			
		JP63-101830A (w/Abstract)	05/1988	Japan			
		JP63-101832A (w/Abstract)	05/1988	Japan			
		JP04-170520A (w/Abstract)	06/1992	Japan			
OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages, etc.)							
EXAMINER					DATE CONSIDERED		
Examiner: Initial if citation considered, whether or not citation is in conformance with M.P.E.P. 609; draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.							

Date: July 27, 2005